

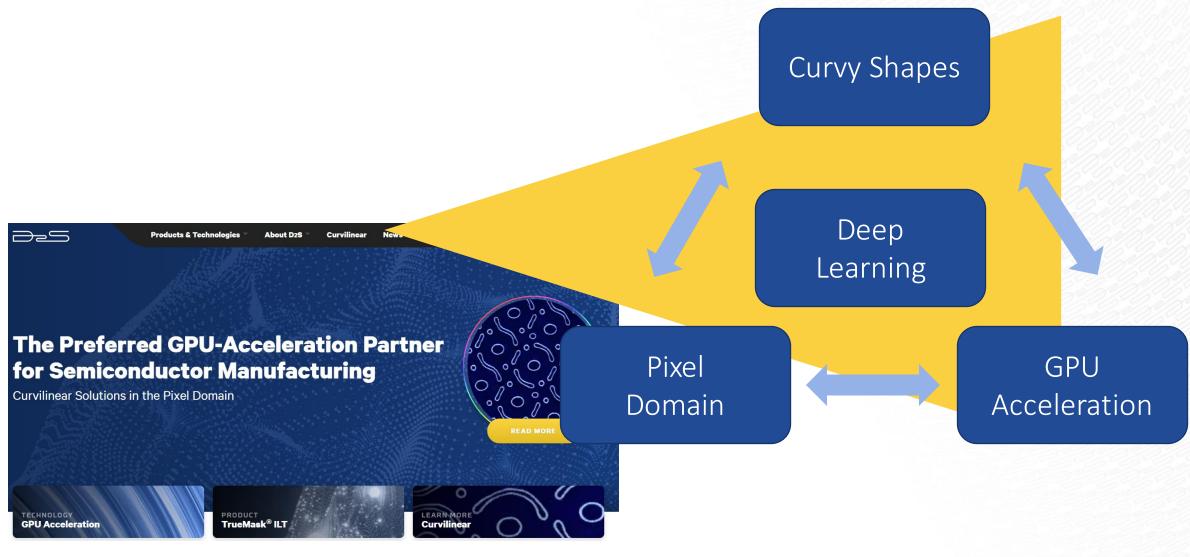


September 2022 | Aki Fujimura, CEO D2S, Inc.

O(p): GPUs, Pixels, DL, Curvy Masks & Designs



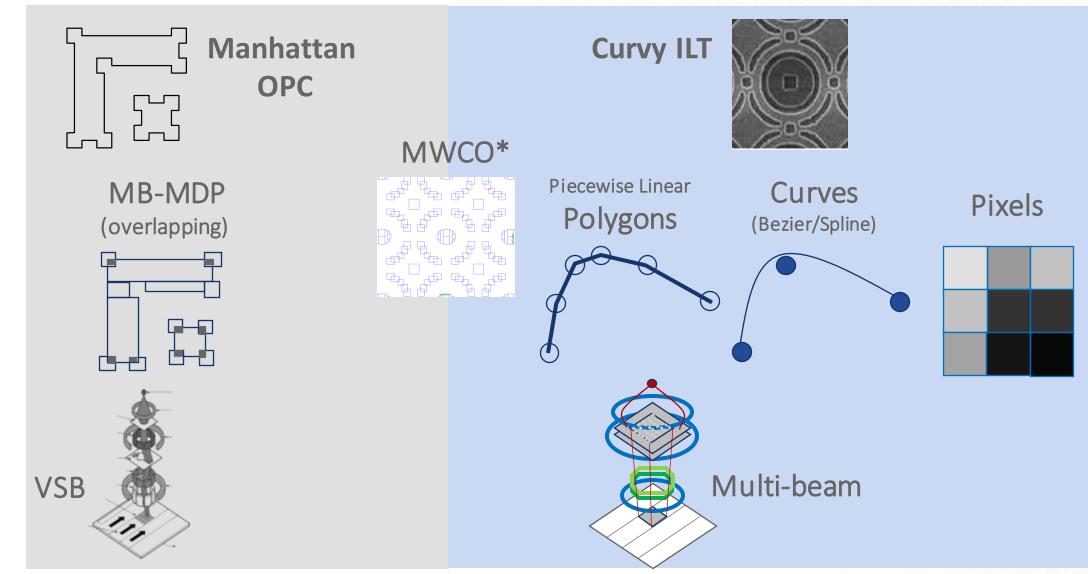
D2S Does GPU Acceleration







GPU Accelerates Edge Manipulation, Too





Fracturing



GPU is Great for Curvy

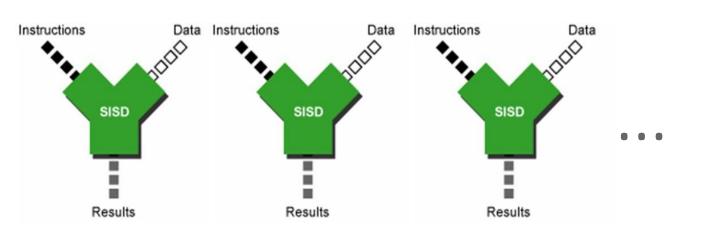


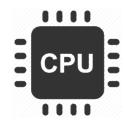
Because GPU is even better at pixels



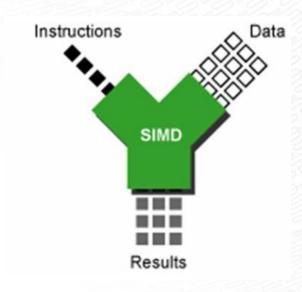


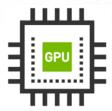
GPU is SIMD and SIMD is Great at Pixels





Multiple Single Instruction Single Data (SISD)



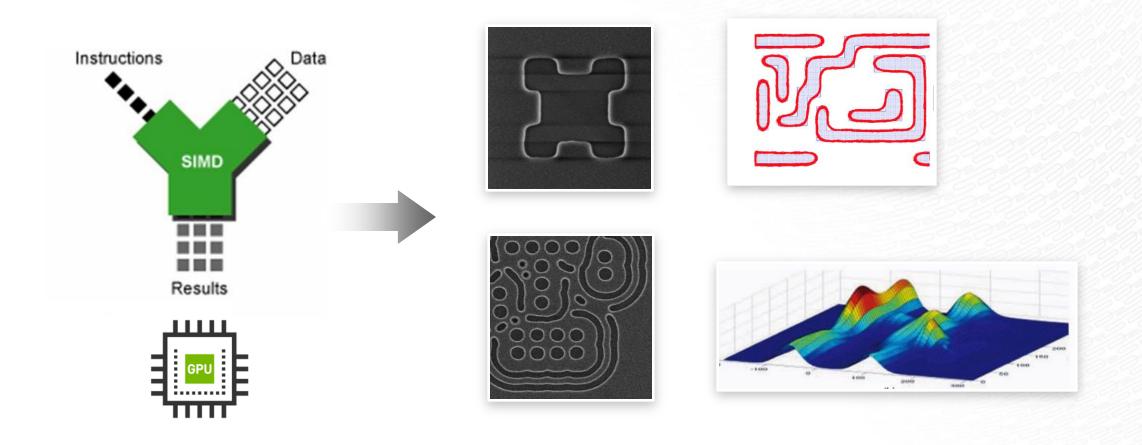


Single Instruction Multiple Data (SIMD)





Mask and Wafer Effects are SIMD

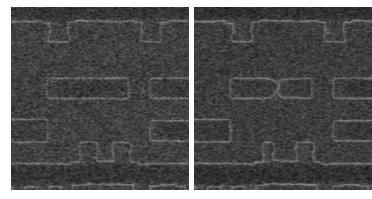


Because nature is SIMD



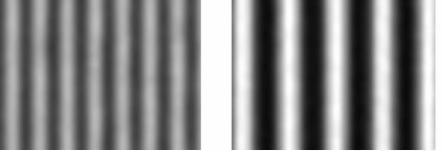


Image Processing is SIMD, Too



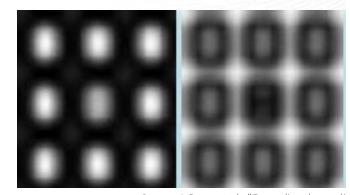
Source: NuFlare/CDLe

SEM



Source: Lasertec/BACUS Newsletter

Inspection



Source: L Pang, et al., "Expanding the applications of computational lithography and inspection (CLI) in mask inspection, metrology, review, and repair"

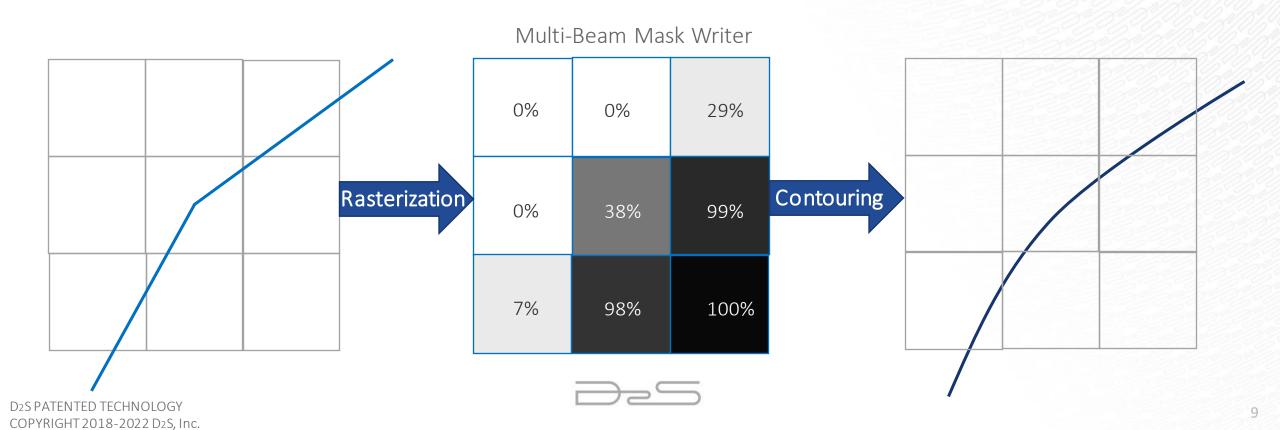
Because Images are Arrays of Pixels





Pixel-Based and Edge-Based are Duals

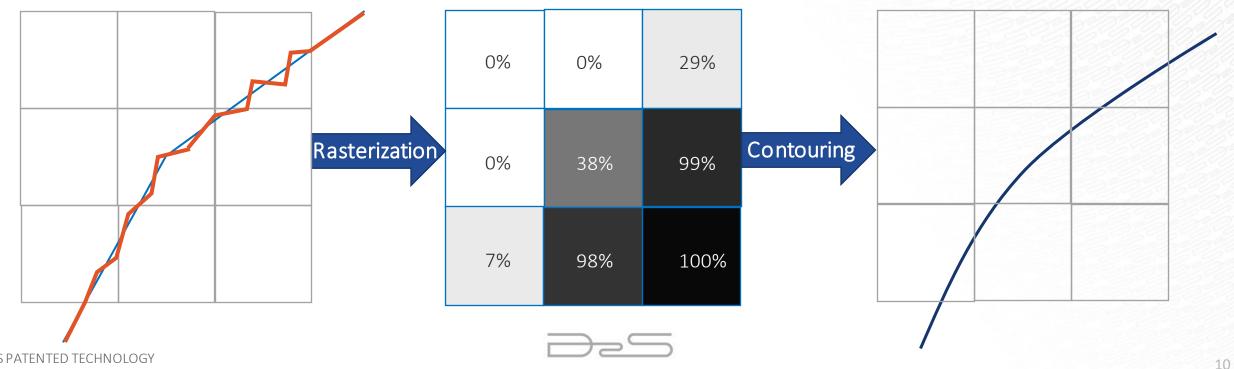
- Whatever you can do in one can be done in the other...given a resolution limit determined by "Nyquist"
- The only question is performance....





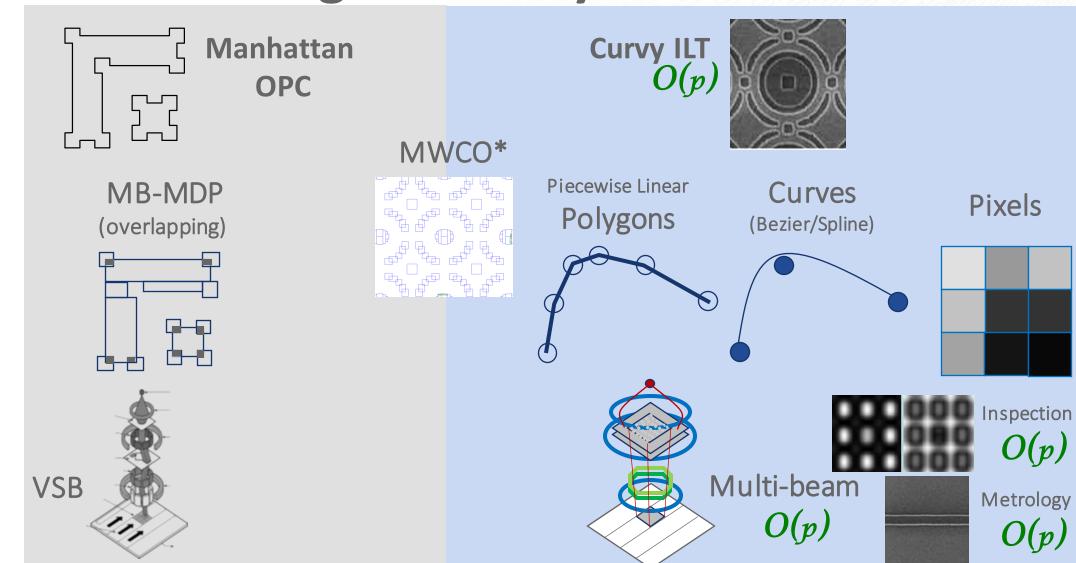
This Also Rasterizes Exactly the Same

- Rasterization is inherently a low-pass filter
- Red and blue become the same in pixels, but red uses much more data
- Curvilinear format would also become the same in pixels and thereafter
 - And represents the actual contoured shape that would be on the physical mask





Mask-Making is Already Pixel-Based





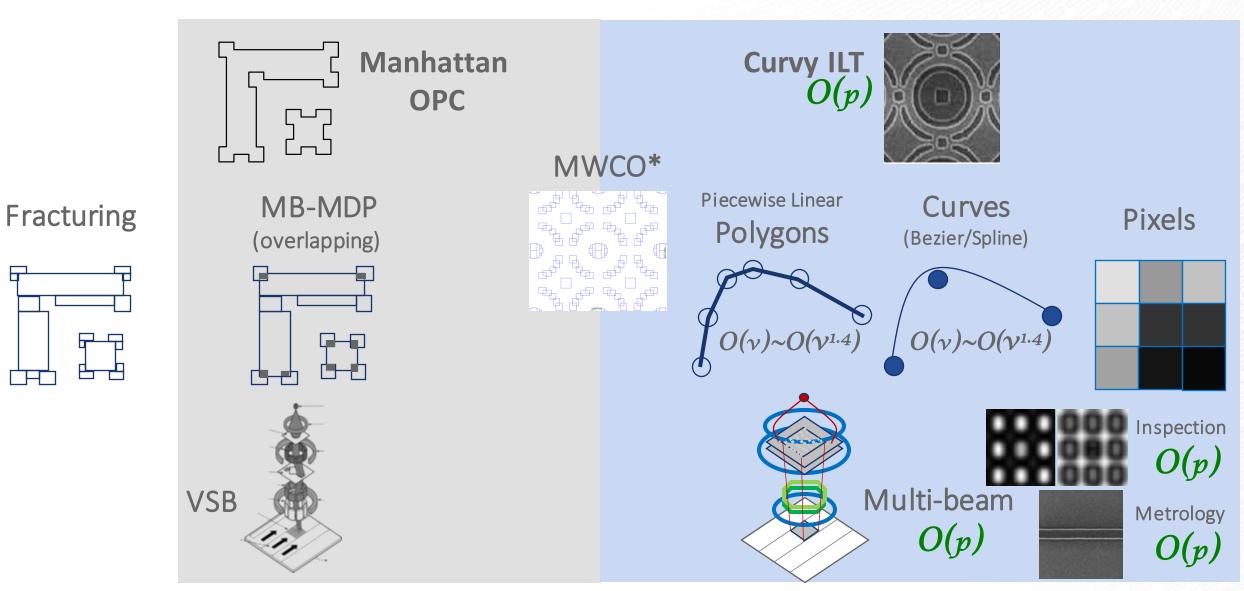
Fracturing



D₂S PATENTED TECHNOLOGY

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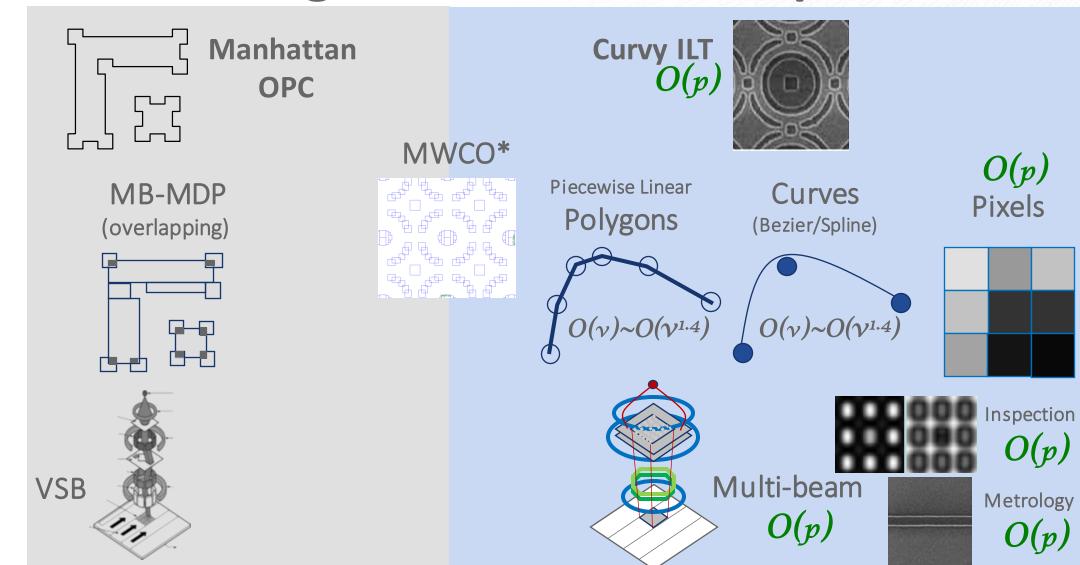
Datapath is Not







D2S is Adding a Pixel-Based Datapath



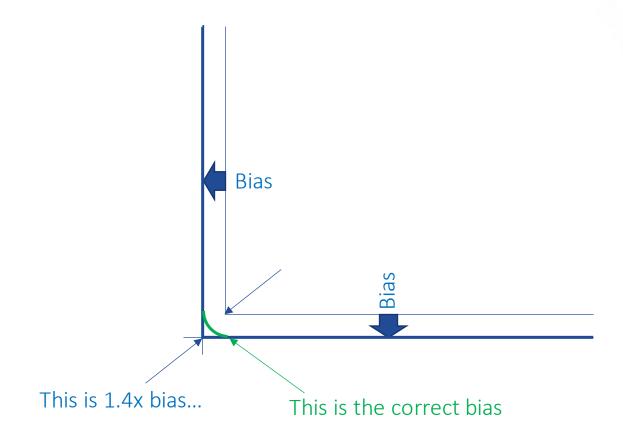


Fracturing



Edge or Pixel, Curvy Improves Manufacturing

Simple example: Biasing



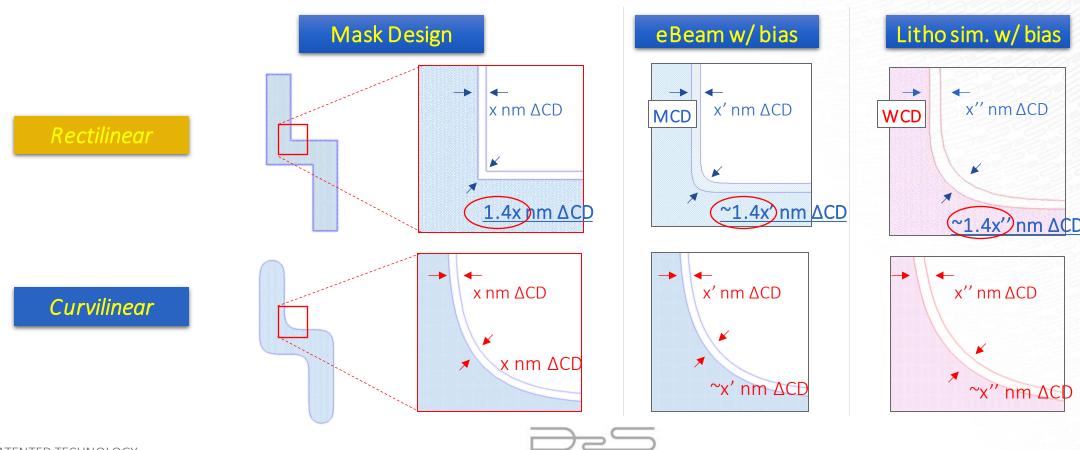
For traditional Manhattan edge-based CAD, it is bad to have bias create curvy shapes. So this is understandable but incorrect. Etching, for example, doesn't work that way.





Even a Simple Bias Operation is Better with Curvy

Rectilinear bias is off by 40% on corners

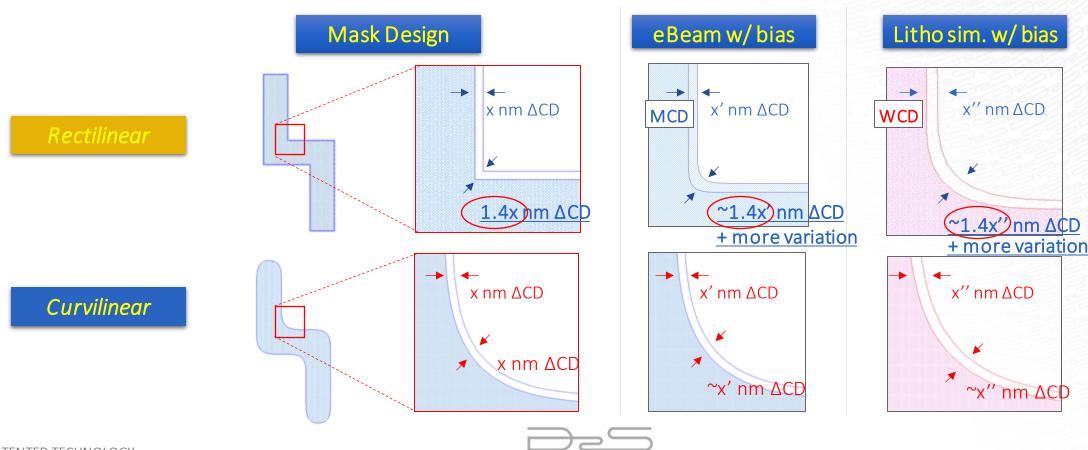


~1.4x′′)nm Δ¢D



Even Worse is Manufacturing Variation

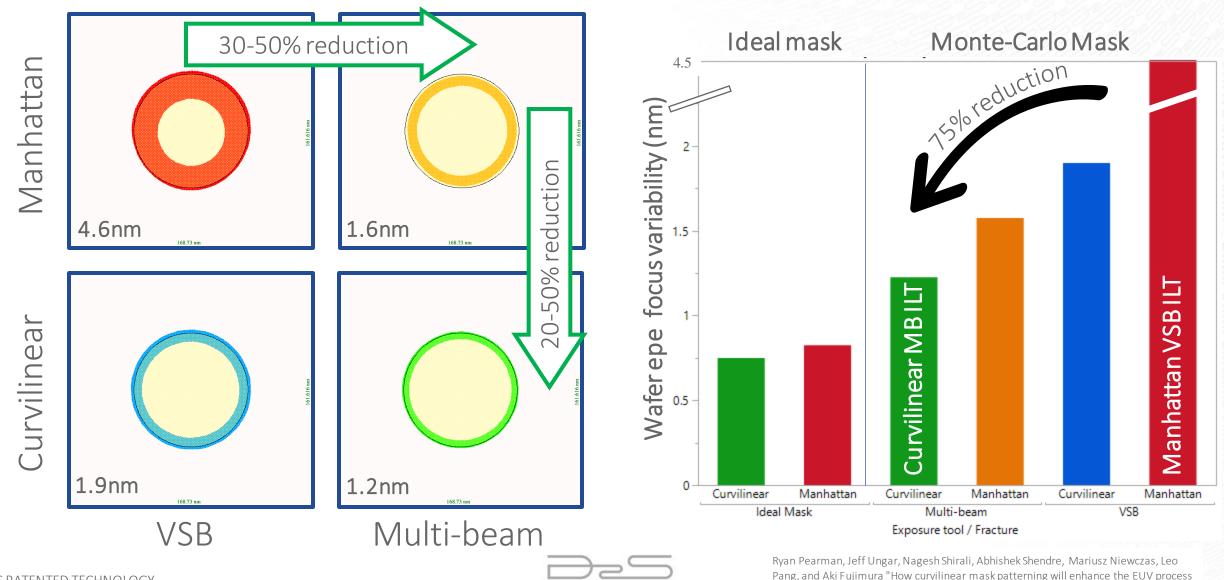
Dose margin is bad on 90° corners



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Beam Manufacturable Shapes are More Reliably Manufacturable

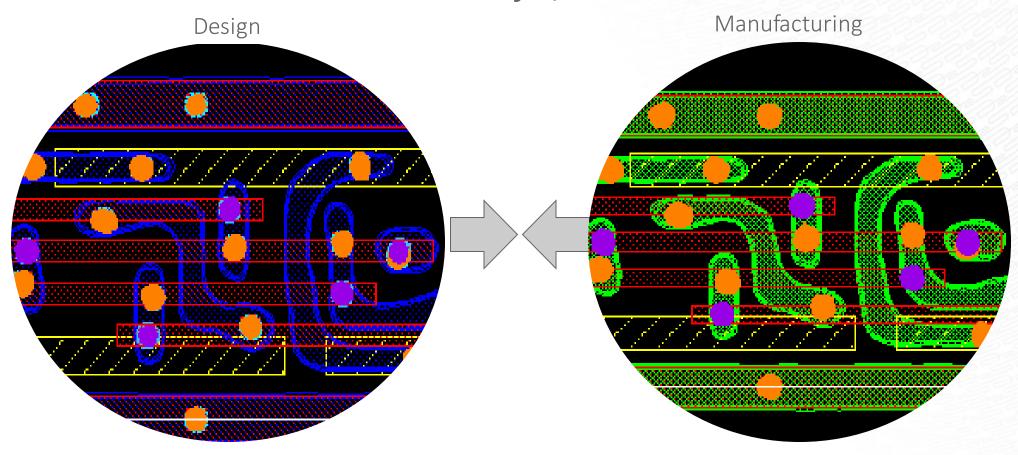


window: a study using rigorous wafer+mask dual simulation", Proc. SPIE 11178, (2019)



Manufacturable Shapes are More Reliably Manufacturable

On Wafer, too



First thing ILT does is to compute manufacturable curvy targets anyway





I Presented This at Design Automation Conference

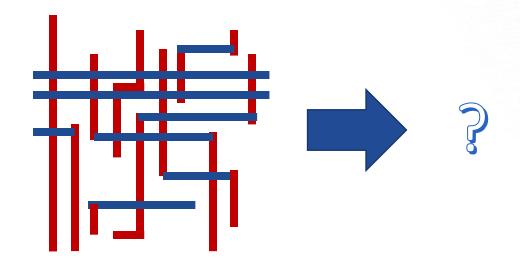
"I was in EDA physical design since 1979 so I know it's important for you to know: Curvilinear Designs are Now Manufacturable. In fact, More Reliably Manufacturable."







Is it Time to Break the Manhattan Assumption?

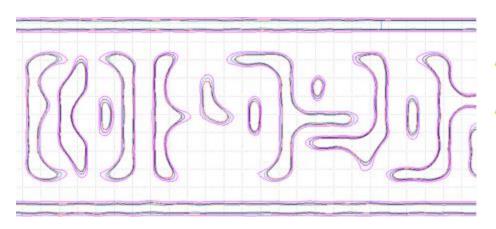


Most chips are interconnect-limited; Reducing vias will reduce routing congestion





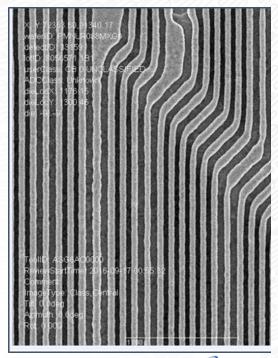
Curvy Designs are Better for Designers, Too



- Manufacturable Curvy Designs
- Improves, all at the same time
 - Yield
 - Power
 - Performance
 - Area



- VSB mask writing
- EDA infrastructure



Micron

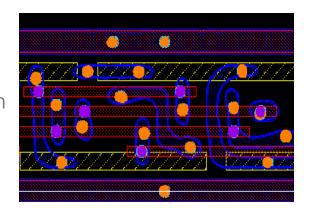




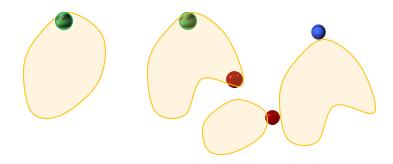
General Perception: "Everything has to Change"

Actually: Only Routing plus Performance Improvements

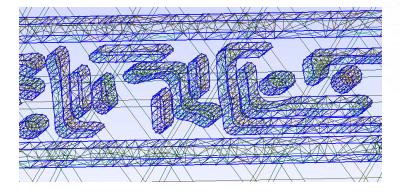
Custom Design

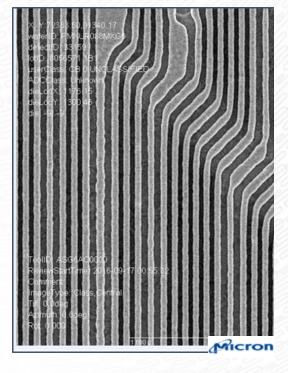


DRC/LVS



Parasitic Extraction



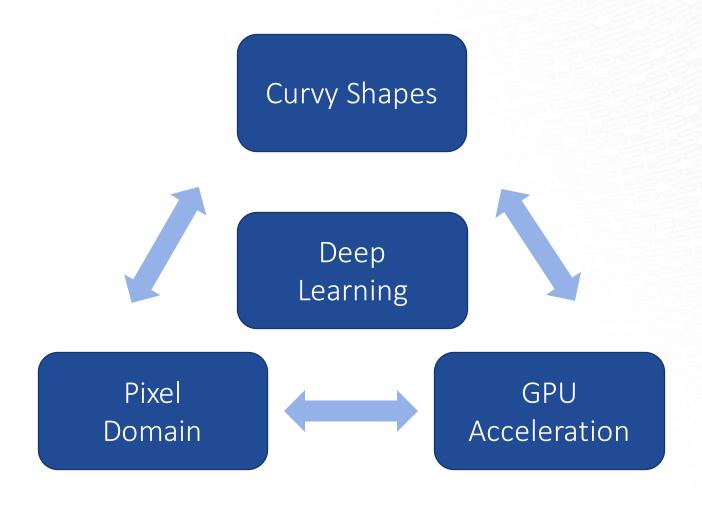


Routing





Curvy-Pixel-GPU Can Work for Them, Too



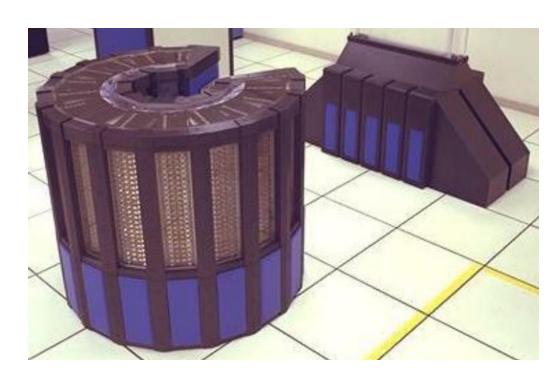


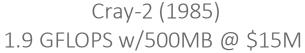


Today's GPU Workstation = 8,000 Cray-2s

60,000,000x Price Performance

It's time to rethink EDA







nVIDIA RTX 3090 Ti (2021) 15,300 GFLOPS w/24GB @ \$2,000

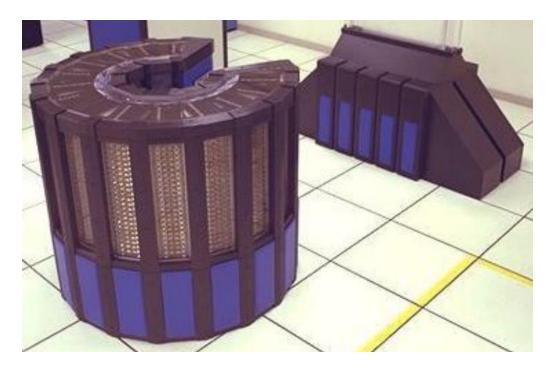




16,000? Today's GPU Workstation = 8,000 Cray-2s

150,000,000x? 60,000,000x Price Performance

It's definitely time to rethink EDA



Cray-2 (1985) 1.9 GFLOPS w/500MB @ \$15M



Announced Last Tuesday





